

ARTIST

Heungman RK

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BIO

Heungman was born in China, brought up in Hong Kong and lives in New York City. He earned a BA in Cinema and Television Arts from California State University and a BFA in Photography and Imaging from Art Center College of Design in Los Angeles. He has been working as a photographer in New York for more than 25 years. His work had been published in Rolling Stone, Times, Spin, Seventeen, Paper, and New York Magazine, amongst others. He is currently living between New York and Spain and focusing on personal projects and exhibitions.

EDUCATION

BFA in Photography, Art Center College of Design, Los Angeles, California

BA in Cinema and Television Arts, California State University, Northridge, California

EXHIBITIONS

2026: RAILOWSKY, Valencia, Spain

2025: RAILOWSKY, Valencia, Spain

2024: FUCAR22 Art Gallery, Madrid, Spain

2023: RAILOWSKY, Valencia, Spain

2020: CLIO ART FAIR, NewYork, USA

2018: CLIO ART FAIR, NewYork, USA

2016: RUSH ARTS Gallery, NewYork, USA

2012: RUSH ARTS Gallery, NewYork, USA

2011: ART LABOR Gallery, Shanghai, China

2011: CROSSING ART, NewYork, USA

2011: SHANGHAI CONTEMPORARY Art Fair, Shanghai, China

2010: PINGYAO International Photo Festival, Pingyao, China

2010: ART LABOR Gallery, Shanghai, China

2010: CROSSING ART, NewYork, USA

2010: BROADWAY Gallery, NewYork, USA

2009: BROADWAY Gallery, NewYork, USA

2009: CHINA SQUARE Gallery, NewYork, USA

2009: INES DE SEROUX Gallery, NewYork, USA

2008: ART WORLD PROJECT, Austria and Worldwide

2008: THREE ON THE BUND, Shanghai, China
2008: ART LABOR Gallery, Shanghai, China
2008: ARTWALK, HongKong, China
2007: EDGE Gallery, HongKong, China
2007: ART LABOR Gallery, Shanghai, China
2006: MUD ArtSpace, HongKong, China
2006: ISLAND6 Gallery, Shanghai, China

REVIEWS

NewYork Art Beat, Feb 2010
Urbanatomy, April 2009
That's Shanghai, August 2008
China Daily, May 2007
Vision Magazine, May 2007
Goethe News, March 2007
Artron News, March 2007
Vision Magazine, April 2006